## Form 1449 (Modified)

Information Disclosure Statement By Applicant APR 0 3 2000

(Use Several Sheets in Necessary)

Atty Docket No. LAM1P133 Applicant:

O'DONNELL

Filing Date 12/27/99 Application No.: 09/472,757

Group 1765

U.S. Patent Documents

Examiner						Sub-	Filing
Initial	No.	Patent No.	Date	Patentee	Class	class	Date
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Examiner		Document	Publication	Country or		Sub-	Trans	slation
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L.J.W.E.	20	Lam Research Corp., Wafer Demonstration Report for Micro 5864/5865, 9/99	chip	Technology

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Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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Form 1449 (Modified)

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Information Disclosure statement By Applicant

Se Several Sheets if Necessary)

Atty Docket No. LAM1P133/P0582

Applicant:
O'DONNELL

Filing Date **12/27/99** 

Application No.: **09/472,757** 

Group 1765

**U.S. Patent Documents** 

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Initial	No.	No.	Date	Patent Office	Class	class		No
LJ. W.E.	K	WO 97/ 11482	27-03-97	PCT	H01L	A2	Yes	
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2.594	P	PCT International Search Report, US/ISA, International Application No. PCT/US 00/35165, Washington, D.C., May 14, 2001
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Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.